PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

re: Koh et al.

Attorne Daoks

5649-1144

pplication Serial No.: 10/625,452

Filed: July 23, 2003

Methods of Forming Semiconductor Devices Using an Etch Stop Layer For:

Date: August 29, 2005

Confirmation No.: 7953

Group Art Unit: 1765

Examiner: Lan Vinh

Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

REQUEST FOR RECONSIDERATION

Sir:

Applicants provide the present Amendment to address the issues raised in the Office Action mailed April 27, 2004.

A listing of the Claims begins on page 2 of this paper

Remarks begin on page 7 of this paper.

It is not believed that an extension of time and/or additional fee(s), including fees for net addition of claims, are required, beyond those that may otherwise be provided for in documents accompanying this paper. In the event, however, that an extension of time is necessary to allow consideration of this paper, such an extension is hereby petitioned under 37 C.F.R. §1.136(a). Any additional fees believed to be due in connection with this paper may be charged to our Deposit Account No. 50-0220.